Boosting and Balancing Electron and Hole Mobility in Single- and Bi-Layer WSe₂ Devices *via* Tailored Molecular Functionalization

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ABSTRACT: WSe₂ is a layered ambipolar semiconductor enabling hole and electron transport, which renders it a suitable active component for logic circuitry. However, solid-state devices based on single- and bi-layer WSe₂ typically exhibit unipolar transport and poor electrical performances when conventional SiO₂ dielectric and Au electrodes are used. Here, we show that silane-containing functional molecules form ordered monolayers on the top of the WSe₂ surface, thereby boosting its electrical performance in single- and bi-layer field-effect transistors. In particular, by employing SiO₂ dielectric substrates and top Au electrodes, we measure unipolar mobility as high as $\mu_h = 150 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ and $\mu_e = 17.9 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ in WSe₂ single-layer devices when *ad hoc* molecular monolayers are chosen. Additionally, by asymmetric double-side functionalization with two different molecules, we provide opposite polarity to the top and bottom layer of bi-layer WSe₂, demonstrating nearly balanced ambipolarity at the bi-layer limit. Our results indicate that the controlled functionalization of the two sides of WSe₂ mono- and bi-layer flakes with highly ordered molecular monolayers offers the possibility to simultaneously achieve energy level engineering and defect functionalization, representing a path towards the deterministic control over charge transport in 2D materials.

KEYWORDS: WSe₂, molecular functionalization, self-assembled monolayers, ambipolar FETs, 2D materials

2D materials (2DMs) are emerging as a potential alternative to silicon technology for next-generation opto- and nano-electronics.^{1,2} While the semi-metallic character of graphene³ hampers its application in electronics, transition metal dichalcogenides (TMDs) include semiconducting compounds with a bandgap in the visible range⁴. This class of materials can be exfoliated down to the single layer and are already being employed as active component in high-performance field-effect transistors (FETs).⁵⁻⁷

An exemplary case of semiconductive TMD is WSe₂, that holds great potential for complementary digital logic applications,⁸ since it can transport both holes⁹⁻¹⁴ and electrons.^{13,14} High performance *p*- and *n*- type FETs were fabricated by employing Pd,^{11,14} In¹⁵ or Ag^{15,16} electrodes, which are characterized by an optimal work function to match either the conduction (In and Ag) or the valence (Pd) band of WSe₂. The choice of optimal metals ensures nearly-ohmic injection for one type of carrier (holes when Pd is used, electrons when In and Ag are used), but poor injection for the other carrier type, leading to unipolar transport.^{11,17}

In order to observe ambipolar transport in WSe₂, ionic liquid gating¹⁸⁻²⁰ and ferroelectric polymers¹⁴ were used in order generate electric fields strong enough to align the valence and conduction band of WSe₂ to the Fermi level of the electrodes. Using solid-state dielectric, ambipolar transport could only be observed by contacting the same WSe₂ flake with a pair of electrodes composed of different metals, one ideal for electron- and the other one for hole-injection.¹⁷

Apart from metal contact engineering, other sophisticated device optimization strategies were adopted to achieve the highest unipolar mobilities reported for single layer WSe₂ ($\mu_h > 200 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$, $\mu_e > 250 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$)^{11,15}, including encapsulation^{11,15}, chemical doping¹¹ and/or the use of high-k dielectrics^{15,20}. On the contrary, very poor charge carrier mobility ($\mu_h, \mu_e < 10^{-2} \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$) and $I_{\text{ON}}/I_{\text{OFF}}$ ratios ($< 10^2$) were achieved in single-layer WSe₂ FETs fabricated when using Au contacts and SiO₂ substrates,^{21,22} which are

the prototypical materials employed as electrodes and dielectrics in 2D electronics. For this reason, WSe₂ remains less investigated than unipolar MoS₂ in field-effect devices, despite its higher intrinsic mobility and ambipolarity.

In order to improve the device performances, the engineering of the energy levels of the 2DM through functionalization with molecules represents a valuable alternative to the use of diverse metals.^{9,23–29} In this context, self-assembled monolayers (SAMs), *i.e.* ultra-thin molecular layers that are covalently attached to the target surfaces,³⁰ are particularly appealing since their ordered structure, framed by the self-assembly, ensures a parallel out-of-plane alignment of molecular dipoles, causing a profound change of surface energy and electronic properties of the functionalized surface.^{31,32} Structural defects in TMDs, such as vacancies and substitutional atoms,^{33,34} represent an ideal anchoring site for covalent functionalization.^{35,36} However, since defects are relatively rare in pristine TMDs,³⁷ their functionalization leads to the presence of isolated molecules,³⁷ and not to the formation of ordered SAMs that could be exploited to tune deterministically the energy levels of TMDs.

Here, we exploit functionalization with ordered molecular monolayers to demonstrate that Au electrodes can be used to inject efficiently both electrons and holes into single- and bi-layer WSe₂ on SiO₂. In particular, we demonstrate high performance unipolar *p*- and *n*- type transistors based on WSe₂ single layers with top Au electrodes on SiO₂, reaching mobilities as high as $\mu_h = 150 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ and $\mu_e = 17.9 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ and $I_{\text{ON}}/I_{\text{OFF}}$ ratio exceeding 10^7 for the *p*-type transistors. Additionally, we provide opposite electronic functionalities by engineering a double-sided molecular functionalization to the two sides of bi-layer WSe₂ flakes, thereby attaining almost balanced ambipolar transport with the same electrode metal on a solid-state dielectric. Such control over charge transport is achieved through functionalization of both SiO₂ and WSe₂ surfaces with molecules containing silane groups, which form ultra-thin, ordered and densely packed layers both on insulating SiO₂ and on semiconducting WSe₂. While the formation of such ordered layers on SiO₂ is well established, our results indicate that silane groups covalently bind at defect

sites naturally present at WSe₂ surface, enabling the effective defect functionalization. On the same time, strong intermolecular interactions ensure the formation of a highly ordered molecular layer, which covers WSe₂ surface evenly, making it possible to modify its electronic properties. In this way, we simultaneously achieve defect functionalization and energy level tuning, and ultimately engineer the charge transport in single and bi-layer WSe₂.

RESULTS AND DISCUSSION

Trichloro(1H,1H,2H,2H-perfluorooctyl)silane (PFS) and N-[3-(Trimethoxysilyl)propyl]ethylenediamine (AHAPS) (see chemical structures in Fig. 1a and b) were selected for the functionalization of both SiO₂ and WSe₂, since the fluorine-rich PFS was demonstrated to induce *p*-doping effect on 2D materials,³⁸ while the amine groups in AHAPS are expected to generate *n*-type doping.³⁹ In order to engineer the electrical characteristics of WSe₂, we followed two distinct approaches. First, mechanically exfoliated WSe₂ single layers were transferred onto SAM-functionalized SiO₂ substrates and subsequently contacted with metal electrodes (see Fig. 1c and d); second, devices based on WSe₂ single layer on untreated SiO₂ were exposed to vapors of two different molecules, deposited from vapor phase on top of the WSe₂ single layer (see Fig. 1e and f).

Figures 1 c and d show the device architecture and transfer characteristics of FETs based on a WSe₂ single layer on PFS- and AHAPS- treated SiO₂ substrate, respectively. The formation of SAMs of both molecules on the SiO₂ surface was confirmed through atomic force microscopy (AFM), X-ray photoelectron spectroscopy (XPS) and contact angle measurements (Fig. S1-S3). The transfer characteristics are also shown for a WSe₂ single layer on untreated SiO₂, which serves as a reference. Such reference device featured poor electrical properties (dashed line in Fig. 1c and d), with very low drain source current ($I < 1$ nA in the entire gate-voltage range explored in this study), corresponding to an electron mobility on the order of 10^{-6} cm²V⁻¹s⁻¹. Such poor performances, which are comparable to those reported for single-layer WSe₂ on SiO₂ substrates with Au electrodes,^{21,22} are caused by the almost-

blocked charge injection from Au into WSe₂, which introduces ultra-high contact resistance. When exfoliated and placed on top of the PFS SAM, WSe₂ based transistors displayed improved charge transport, with higher current balanced ambipolarity but still relatively low hole and electron mobilities ($\mu_h \sim \mu_e \sim 0.5 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$). Similarly, an AHAPS SAM induced strong *n*-doping, displaying an electron mobility approaching $0.4 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$.

A different situation was encountered when exposing WSe₂ single layer devices supported on untreated SiO₂ substrates to the vapors of the two molecules. In this case, the devices were measured before and after top functionalization, so that the effect of the molecules on the electrical characteristics was directly addressed in the same device. Very poor electrical characteristics were measured for the as-fabricated devices (*i.e.* not exposed to PFS vapors), which are similar to the reference FET in Fig. 1a and 1b (dashed line in Fig. 1c and d). After exposure to PFS vapors, a five-orders-of-magnitude increase in the electrical current is observed, with the device exhibiting *p*-type transport with hole mobility $\mu_h = 20 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ (Fig. 1e). Similarly, exposure to AHAPS vapor causes a three-order-of-magnitude increase in the electrical current, with the device displaying an almost degenerated *n*-doping, with an *n*-type mobility of $7 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ (Fig. 1f). An analogous performance improvement can be observed in the WSe₂ output characteristics (Fig. S4). Before functionalization, the $I_{\text{DS}}\text{-}V_{\text{DS}}$ traces display very low current and are highly non-linear, indicating that a significant Schottky-like energy barrier develops at the interface between Au and untreated WSe₂ (Fig. S4a). On the contrary, after functionalization, the $I_{\text{DS}}\text{-}V_{\text{DS}}$ traces become almost ideal (Fig. S4b).

We highlight here that PFS and AHAPS not only possess different functional groups, but also different anchoring groups, respectively trichlorosilane and trimethoxysilane. In order to verify whether different anchoring groups contribute to the effects observed on PFS- and AHAPS-treated WSe₂, we exposed WSe₂ single layers to vapors of hydrochloric acid and methanol, which contain a -Cl atom and a -OMe group, in analogy to trichlorosilane and trimethoxysilane. Figure S5 shows that the electrical characteristics of

WSe₂ single-layer FETs are not modified significantly by exposure to either vapors, ruling out an important contribution of the anchoring groups to the modification of the WSe₂ electrical characteristics shown in Fig. 1. Therefore, the different effect of PFS and AHAPS can be ascribed to the different functional groups, *i.e.* the fluorinated chains in PFS and the amine groups in AHAPS.

The treatment with PFS and AHAPS vapors also changes drastically the optical properties of WSe₂. In particular, we characterized the photoluminescence (PL) of WSe₂ single layers before and after the treatment with AHAPS and PFS at 77 K, as shown in Fig. 1g,h. The pristine WSe₂ single layer shows the typical spectral features, characterized by an exciton peak X_0 at 1.73 eV and a smaller peak at lower energy (1.69 eV) corresponding to the negative trion X^- .⁴⁰ A small peak is also visible at 1.60 eV, which was described as a defect-related exciton, indicating the presence of defects in the untreated WSe₂ single layer.⁴¹ After exposure to PFS vapor, the intensity of the PL spectrum of the same flake was decreased by a factor 2, and its spectral features were significantly modified. In particular, the peak corresponding to the negative trion X^- disappeared, while a additional feature arose at 1.71 eV, which can be explained as a positive trion peak X^+ (Fig. 1g). Since positive trions are bound states consisting of two holes and one electron,⁴¹ the increase in their relative abundance with respect to neutrally charged excitons is indicative of hole doping, in good agreement with the electrical characterization. In the case of the AHAPS treatment, the PL change after functionalization is even more important. After functionalization, the PL intensity decreases almost by one order of magnitude, and the most intense peak in the spectrum is the negative trion X'^- at 1.67 eV (Fig. 1h), which indicates that the AHAPS introduces a high density of electrons.⁴⁰

While the effect of the functionalization of SiO₂ on the electrical characteristics of WSe₂ (architecture reported in Fig. 1c and d) could be expected on the basis of similar results reported for MoS₂³⁹, the improved charge injection and the consequent increase in mobility observed upon exposure of the WSe₂ surface to vapor of different molecules (architecture reported in Fig. 1e and f) was unexpected. AFM

imaging performed on PFS functionalized WSe₂ reveals that the adlayer displays a rather flat morphology forming a discontinuous ultra-thin film with a surface coverage estimated to be less than 60% (Fig. 2a). As evidenced in the topographical profile displayed in Fig. 2b the height of the adlayer is (1.2 ± 0.4) nm, consistently with the 1.34 nm contour length of PFS, suggesting that the molecules are perpendicularly oriented on the surface of WSe₂.⁴² In order to increase uniformity and surface coverage of the molecular layer, we treated WSe₂ surface with ozone before exposing it to the molecular vapors (see Methods section). For ozone-treated WSe₂, the morphology of the PFS layer is markedly different, as it covers completely the WSe₂ surface (Fig. 2c). In the same way, a continuous thin film is obtained when an ozone-treated WSe₂ layer is exposed to AHAPS vapors (Fig. 2d). Water contact angle measurements of pristine, PFS-treated and AHAPS-treated WSe₂ surface are shown in Figs. S6. Interestingly, the water contact angles measured for the functionalized WSe₂ surfaces are very similar to those measured for the functionalized SiO₂ surfaces (Fig. S3), suggesting that the molecules are ordered in the same way in both cases.

Complementary, information on the molecular orientation was obtained by angle-resolved XPS. In particular, we observed that the core levels of the molecular adlayer and those of WSe₂ are attenuated differently as a function of the angle (*i.e.* 0 deg or 60 deg), indicating a preferential vertical orientation of the molecules with respect to the substrate normal (Fig. S7). All together, these data reveal that PFS and AHAPS form ordered monolayers not only on SiO₂, but also on WSe₂, and that the molecular ordering is analogous on the two surfaces.

Nevertheless, the interaction between WSe₂ and the molecular layer is very different in case WSe₂ single layers were transferred onto SAM-functionalized SiO₂ substrates (Fig. 1c,d) or treated with molecular vapors (Fig. 1e,f). In the first case, the bottom surface of WSe₂ single layers is in contact with the exposed F or NH₂ functional groups. On the contrary, in the second case AHAPS and PFS form an ordered molecular layer on top surface of the WSe₂ in which the silanol groups lie close to the surface of WSe₂,

leading to completely different behaviors and resulting in different effects on the WSe₂ electronic properties.

In order to understand the origin of the improved performances after molecular functionalization discussed in Fig.1, we performed ultraviolet photoemission spectroscopy (UPS) and XPS. In particular, while UPS provides valuable information on the work function changes in the system, XPS accesses the atomic core levels, allowing to describe the effect of molecular functionalization with elemental sensitivity. Figures 3a and b show the variation in the work function of pristine and functionalized WSe₂ bulk crystals, as extracted by UPS. The presence of the AHAPS monolayer reduces the work function by 0.4 eV indicating an *n*-type doping. In the case of the PFS monolayer, the functionalization results in a work function increase of 0.45 eV, which indicates *p*-type doping, in good agreement with the electrical characterization shown in Fig. 1e. We highlight that the shift in WSe₂ energy levels also implies that charge carrier injection from Au is different. In particular, a significant Schottky energy barrier takes place at the interface between Au and untreated WSe₂, impeding an efficient injection of electrons and holes. In these conditions, the device resistance is dominated by the high contact resistance, leading to the poor electrical performances shown in Fig. 1. On the contrary the increased (decreased) work function of PFS (AHAPS)-functionalized WSe₂ results in the improved alignment between the WSe₂ valence (conduction) band and Au work function, therefore favoring the injection of holes (electrons). In turn, the improved charge injection lowers the contact resistance, and permits to access the intrinsic electrical properties of WSe₂, enabling the several-orders-of-magnitude improvement in the hole and electron mobility for treated WSe₂.

The work function variation observed in this study is comparable to that measured for ordered SAMs of similar molecules,^{43,44} further confirming that the molecular monolayers on WSe₂ are highly ordered and densely packed, leading to an excellent alignment of the molecular dipoles at the surface, which induces a local change in WSe₂ energy levels.

Figure 3 c and d shows the XPS spectra of W 4f and Se 3d core levels before and after AHAPS and PFS functionalization, respectively. The W 4f and Se 3d peaks shift to higher (lower) binding energy after functionalization with AHAPS (PFS). In this regard, the shift in the position of the W 4f and Se 3d core levels is in agreement with the change of the work function, *i.e.* a higher (lower) binding energy shift is observed when the work function is decreased (increased). This finding indicates that the energy levels of the uppermost WSe₂ layers are affected by the presence of the molecular dipoles, which generate an electric field effect analogous to that of a gate electrode.^{43–45} Moreover, XPS also shows that the line shape of both W 4f and Se 3d core levels remains almost unchanged upon functionalization with either molecules, except for the shift in energy. This finding indicates that the W-Se chemical bonds are not altered significantly, permitting to achieve excellent electrical performance in FETs WSe₂.

In order to cast light onto the role of the silanol group, we measured the effect of other molecules containing a similar functional core yet exposing different anchoring groups on the electrical characteristics of WSe₂ single layers. In particular, we focused our attention on PFS, and chose another two perfluorinated molecules with the same length but with different anchoring end groups, namely 2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-Pentadecafluoro-1-octanol (PDFO) and 1H,1H,2H-Perfluoro-1-decene (PFD). While PFS possesses a trichlorosilane group that can be hydrolyzed into a silanol group, PDFO is terminated by an alcohol group, and PFD exhibits an alkene head. Figure 4 a-c shows the effect of the different perfluorinated molecules onto WSe₂ single layers. As discussed above, the exposure of WSe₂ single layers to PFS vapor introduces significant *p*-doping and an important increase in mobility (Fig. 4a). Instead, the exposure to PDFO vapor only results in a minor *p*-doping, with minimal effect on the mobility, which remains in the range 10^{-5} - 10^{-6} cm²V⁻¹s⁻¹ (Fig. 4b). In the same way, an analogous treatment with PFD leads to a further degradation of the WSe₂ electrical performances (Fig. 4c).

To elucidate the nature of the interaction between the top molecular monolayer and the WSe₂ surface, we used XPS to characterize the surfaces of bulk WSe₂ crystals exposed to vapors of the three different

molecules and subsequently washed by sonication in ethanol and toluene. In particular, in Fig. 4d-f we show the F 1s core level spectra measured for PFS-, PDFO- and PDF-treated WSe₂, respectively. For the PFS-treated WSe₂ (Fig. 4d), an intense F 1s peak is found, *i.e.* a significant amount of molecules still bound to the surface after sonication, indicating a strong interaction between PFS and WSe₂. On the contrary, for the PDFO-treated surface (Fig. 4e), only traces of F atoms are measured after the washing step, demonstrating that the vast majority of molecules has been wash out. A similar situation is encountered for PFD (Fig. 4f), for which no F peak is observed after sonication.

Overall, the presence of PFS molecules on WSe₂ after washing and sonication treatment suggests the formation of a stable interaction, which could be covalent in nature. However, the negligible change of W and Se core levels in the XPS spectra before and after molecular functionalization, rule out a massive covalent interaction. This apparent inconsistency could be explain considering that only a few molecules in the top monolayer form covalent bonds to isolated intrinsic defects in the WSe₂ crystal structure. Indeed, the trichlorosilane group in PFS and the trimethoxysilane group in AHAPS can be hydrolyzed into a silanol group in presence of residual traces of water.⁴⁶ In turn, the silanol groups can generate covalent bonds to oxygen substitutional atoms present in the WSe₂ structure,⁴⁷ and/or to Se vacancies, which were reported to form covalent bonds with O.³⁵ Additionally, it is well known that polymerization often takes place in silane-based SAMs, with bridges forming between silanol groups belonging to neighboring molecules.³⁸ In this way, the PFS monolayer is composed of a polymerized layer of orderly aligned molecules, strongly anchored to the WSe₂ surface through covalent bonds at sparse defect sites (Fig. 4g).

In contrast, the alcohol group of PDFO, which might bind to defects in WSe₂, does not possess additional binding sites for polymerization; hence, most molecules are simply physisorbed on the WSe₂ surface and are removed by the sonication procedure, which only leaves the few molecules chemisorbed

at defect sites (Fig. 4h). Similarly, the alkene head of PFD prevents any covalent interaction with WSe₂ (Fig. 4i), and the molecules are efficiently desorbed by sonication in solvents.

Our understanding of the anchoring mechanism for the PFS monolayer allows us to further engineer the functionalization. In particular, as discussed above, we found that an ozone treatment prior to the functionalization improves the coverage of the top monolayers. Indeed, the ozone treatment increases the number of O substitutional atoms in the structure of WSe₂ single layers⁴⁸ (as evidenced by XPS, see Fig. S8), which serve as anchoring sites for silanol groups, and thus for PFS and AHAPS attachment. Consequently, a higher number of PFS or AHAPS molecules will be able to be anchored to WSe₂ to substitutional oxygen atoms introduced by the UV/Ozone treatment. This results in an improvement of the uniformity of the molecular layer. Therefore, we tested whether the improved coverage corresponds to a further improvement in the electrical performances of WSe₂ field effect transistors. We treated three WSe₂ field effect devices with a short ozone treatment (3 min) and subsequently with the PFS vapor. The short ozone treatment was found to introduce minor *p*-type doping in the electrical characteristics of WSe₂, with only a slight increase in mobility, which remained below 10⁻¹ cm²V⁻¹s⁻¹ (Fig. S9). After exposure to PFS vapor, all devices displayed stronger *p*-type doping and increased hole mobility as compared to the functionalization without ozone treatment (Fig. 5a). Interestingly, hole mobilities up to 150 cm²V⁻¹s⁻¹ were measured for ozone-exposed, PFS-treated WSe₂ single layers contacted by Au electrodes. Moreover, in this case the doping does not degenerate, and an OFF current close to the detection limit $I_{\text{OFF}} = 1$ pA can be reached, yielding an $I_{\text{ON}}/I_{\text{OFF}}$ ratio above 10⁷. Higher doping levels and improved mobilities were also observed for ozone-exposed, AHAPS-treated WSe₂. In this case, electron mobilities up to 17.9 cm²V⁻¹s⁻¹ were measured in WSe₂ single layers contacted by Au electrodes (Fig. 5b). Moreover, we found that the SAM functionalization provides protection against air exposure and temperature cycling (Fig. S10). In particular, after an initial degradation which lasted for 4 days, the electrical characteristics of PFS-based devices remained constant, displaying mobility $\mu_{\text{h}} > 10$ cm²V⁻¹s⁻¹, and $I_{\text{ON}}/I_{\text{OFF}} > 10^5$.

Finally, we demonstrate that an asymmetric functionalization of the two surfaces of the same WSe₂ bi-layer flake (see architecture reported in Fig. 5c) offers the opportunity to harness ambipolar transport at the bi-layer limit. Towards this end, we fabricated a device based on a WSe₂ bi-layer adsorbed on an AHAPS-functionalized SiO₂ substrate, to induce *n*-type doping in the bottom layer. Subsequently, we treated the same bi-layer with PFS vapor, to induce *p*-type doping in the top layer. Figure 5c shows that ambipolar characteristics were measured in the as-obtained asymmetrically functionalized device, with almost balanced mobility ($\mu_h = 20 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ and $\mu_e = 5.7 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$), while retaining an $I_{\text{ON}}/I_{\text{OFF}}$ ratio exceeding 10^3 . On the contrary, for single layers WSe₂, the same approach of asymmetric functionalization did not introduce ambipolar characteristics, and led to degraded charge transport (Fig. S11). This finding can be understood simply by considering that in the case of bi-layer WSe₂ opposite polarity is provided to the top and bottom layers in contact with the different molecular monolayers, which contribute in parallel to the overall charge transport, giving rise to ambipolar transport. Instead, in the case of a single layer WSe₂, the effects of the asymmetric functionalization cancel each other out, ultimately rendering an almost intrinsic WSe₂, analogous to the pristine case.

CONCLUSIONS

In conclusion, we have demonstrated a chemical approach to control and improve charge transport in WSe₂ single- and bi-layers. In particular, we have shown that silane-containing molecules form ordered monolayers on top of the WSe₂ surface, which are similar to those formed by the same molecules on SiO₂ in terms of molecular ordering and packing density. In contrast to previous works in which high performances WSe₂ FETs were achieved by exploiting a more cumbersome method relying on the use as electrodes of metals with a work function matching the conduction or valence band of WSe₂,^{11,15} we demonstrate an alternative strategy by engineering the WSe₂ energy levels to match the Au Fermi level. In this way, our molecularly engineered WSe₂ single layers FET, contacted with conventional Au contacts on SiO₂ dielectrics show *p*- or *n*- mobility as high as $\mu_h = 150 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ and $\mu_e = 17.9 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$.

Moreover, we demonstrated ambipolar transport in bi-layer WSe₂ contacted with the same electrode metal through a double asymmetric functionalization of its top and bottom surfaces. By combining energy level engineering and defect functionalization, silane-based monolayers offer the possibility to provide the desired charge transport characteristics to atomically thin WSe₂ and hence demonstrate high-performance field-effect devices. Based on our results, we anticipate that silane-based monolayers can be employed to couple other molecular functions to Se-based transition metal dichalcogenides, including specific molecular capabilities with no analogue in 2D materials.⁴⁹ Furthermore, local patterning of the two surfaces of the 2D semiconductor may allow bottom-up engineering of lateral heterojunctions.

EXPERIMENTAL METHODS

Sample preparation

SiO₂/Si-n⁺⁺ substrates (from Fraunhofer Institute for Photonic Microsystems IPMS, Dresden, Germany) with 90 nm thick oxide were cleaned in an ultrasonic bath in acetone and isopropanol and dried under nitrogen flow. Afterwards, the substrates were treated by UV/O₃ for 20 min. For the growth of PFS (Sigma Aldrich) SAM on SiO₂, the freshly UV/O₃ treated substrates were placed in a sealed reactor containing 20 μ L PFS, and heated at 75 °C for 90 min. Once cooled back to room temperature, the substrates were rinsed with 20 mL toluene, sonicated 10 s in ethanol, and baked on a hotplate at 60 °C for 1 h. For the growth of AHAPS (Sigma Aldrich) SAM, the freshly UV/O₃-treated substrates were placed in 10 mL toluene containing 7 μ L AHAPS. The solution was then heated at 60 °C for 1 h and then left at room temperature for 11 h. The substrates were then rinsed with 20 mL toluene, sonicated in hexane for 5 s, and baked on a hotplate for 1 h at 60 °C. The AHAPS treated substrates were then immersed in 10 mL toluene with 50 μ L triethylamine for 5 min, and dried on a hotplate at 60 °C for 5 min. The SAM-functionalized surfaces were characterized by water contact angle (Krüss DSA 100) measurements upon deposition of a

3- μ L drop of milliQ water on the surface. Atomically thin WSe₂ flakes were exfoliated *via* a stamp method, using a silicone-based gel film (PF film, retention level X4, gel thickness 6.5 mil) from Gel-Pak on a synthetic WSe₂ single crystal (purchased from HQ Graphene). The single-layer and bi-layer WSe₂ flakes were identified by optical contrast (Olympus BX51) and PL spectroscopy (Renishaw microscope equipped with a 100x objective, $\lambda_{\text{ex}} = 532$ nm, spot size of 800 nm). The low temperature PL characterization was performed with a Linkam THMS600 temperature-controlled stage with a LNP95 cooling system. Using the shadow mask approach (homemade shadow mask, Fig. S12) or the photolithographic approach (AZ1505 photoresist and AZ326 MIF developer from MicroChemicals, Laserwriter LW405B from Microtech), 30 nm gold were thermally evaporated with a Plassys MEB 300, forming the drain and source electrodes on WSe₂. For the vapor treatment of WSe₂, 20 μ L PFS, AHAPS, PDFO (Sigma Aldrich) or PFD (Sigma Aldrich) were poured into a sealed reactor with the samples to treat, and the system was heated at 75 °C for 90 min. When mentioned, a 3 min UV/Ozone treatment was performed with a Novascan PDS Pro Series. Table S1 summarizes the average mobility and ON-OFF ratio measured in WSe₂-based FETs treated in the different ways.

Sample characterization

The devices were electrically characterized by a Keithley dual channel 2636 Sourcemeter, in a three-terminal configuration with the back gate contacted through an underlying metal plate, in a glovebox filled with nitrogen, in dark conditions.

XPS/UPS analyses

X-ray photoelectron spectroscopy (XPS) was carried out with a non-monochromatized Mg K α source (emission line at 1253.6 eV), and ultraviolet photoelectron spectroscopy (UPS) was performed by means of the He I photon at about 21.2 eV. The electron energy analyzer is a VSW HSA100 hemispherical analyzer with PSP electronic power supply and control, the total energy resolution is 0.8 eV for XPS and about 0.1 eV for UPS. The binding energy (BE) scale of XPS spectra was calibrated by using the Au 4f

peak at 84.0 eV as a reference. The secondary electron cutoff (SECO) spectra were measured with a sample bias of -7.0 V.

AFM imaging

AFM measurements were carried out using a Veeco Dimension 3100 atomic force microscope, under the control of a Nanoscope IV unit in ambient conditions. Topographic and phase imaging were recorded while operating in tapping mode, with an antimony *n*-doped silicon cantilever.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: xxxxx.

Figures S1-S12, Table 1 and references (refs 1-5). Characterization of PFS and AHAPS SAMs on SiO₂ surfaces; electrical performances of WSe₂ single layers treated by vapors of HCl and methanol. Water contact angle of pristine, PFS-treated and AHAPS-treated WSe₂ surface. Angle Resolved XPS of AHAPS and PFS functionalized WSe₂. Output characteristics of WSe₂ FET devices before and after treatment. Effect of ozone treatment on the spectroscopic and electrical characteristics of WSe₂. Air and temperature stability on the electrical characteristics of WSe₂. Electrical performances of double functionalized WSe₂ single. Summary of averaged mobilities and I_{ON}/I_{OFF} of field effect transistors based on functionalized WSe₂ single layers. (PDF)

The authors declare no competing financial interests.

AUTHOR INFORMATION

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Author Contributions

M.-A.S., M.G., E.O. and P.S. conceived the experiment. M.-A.S. performed the spectroscopic characterization and carried out the device fabrication and characterization with the aid of T.L. and Y.W.. M.E. carried out the AFM study; S.B. optimized the sample preparation. R.V., M.T. and M.V.N. performed the XPS and UPS experiments. M.G. and M.-A.S. co-wrote the paper. All authors discussed the results and contributed to the interpretation of data as well as to editing the manuscript.

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Figure 1. (a,b) Chemical structure of PFS and AHAPS. (c,d) Device architecture and corresponding transfer curve of single-layer WSe₂ flakes measured with gold contacts on (c) PFS-treated and (d) AHAPS-treated SiO₂ dielectric (90 nm thick) Channel length L and width W: (c) L= 2.6 μ m ; W= 4 μ m (d) L= 6 μ m ; W= 4.6 μ m . For the sake of comparison, the transfer curve of a reference device based on a WSe₂ single layer on untreated SiO₂ surface is also shown (dashed black lines, L=5.4 μ m; W= 2.2 μ m). (e,f) Device architecture and corresponding transfer curve of WSe₂ devices treated with e) PFS and f) AHAPS vapor on untreated SiO₂ dielectric. The transfer curves of the same WSe₂ devices before molecular treatment are shown as dashed black lines. (e) L=3.1 μ m ; W= 1.3 μ m; (f) L=3.6 μ m ; W=1.2 μ m; (g,h) Photoluminescence spectra of WSe₂ single layers at 77 K treated with (g) PFS and (h) AHAPS vapors. The photoluminescence spectra of the pristine WSe₂ single layers are shown in black.

Figure 2. (a) AFM image of the surface of a WSe₂ bulk crystal exposed to PFS vapor. A relatively flat layer covers approximately 60% of the surface. (b) Height profile extracted from image (a). (c,d) AFM images of the surface of a WSe₂ bulk crystal exposed to (c) PFS and (d) AHAPS vapor after ozone treatment. The vertical scale bar is the same.

Figure 3. (a,b) Secondary electron cutoff of (a) AHAPS-treated and (b) PFS-treated WSe₂ surface, compared to the corresponding pristine surface. (c,d) W 4f core level spectra before and after (c) AHAPS and (d) PFS functionalization. (e,f) Se 3d core level spectra before and after (c) AHAPS and (d) PFS functionalization.

Figure 4. (a- c) Transfer curves of pristine WSe₂ single layers on untreated SiO₂ (90 nm thick), exposed to (a) PFS, (b) PDFO and (c) PFD vapor. The chemical structures of PFS, PDFO and PFD are shown above. Channel length L and width W : (a) $L=6.6\ \mu\text{m}$; $W=2.4\ \mu\text{m}$; (b) $L=5.3\ \mu\text{m}$; $W=1.5\ \mu\text{m}$; (c) $L=2.4\ \mu\text{m}$; $W=2.7\ \mu\text{m}$. (d-f) F 1s core level spectra of WSe₂ bulk crystal after exposure to (d) PFS, (e) PDFO and (f) PFD vapor and subsequent sonication in ethanol and toluene. (g-i) schematic illustration of the proposed anchoring mechanism/adsorption on defective WSe₂ (exhibiting vacancies or oxygen substitutional atoms) for each molecule.

Figure 5. Device architecture and corresponding transfer curves of (a,b) WSe₂ single layer with Au contacts, exposed to ozone and (a) PFS vapor and (b) AHAPS vapor. For the sake of comparison, the transfer curves of the pristine WSe₂ single layers are also shown (dashed black lines). (c) Device architecture and corresponding transfer curve of bi-layer WSe₂ after asymmetric functionalization: the bottom WSe₂ layer is in contact with AHAPS-treated SiO₂ dielectric, while the top WSe₂ layer was exposed to ozone and PFS vapor. Channel length L and width W : (a) $L=3\ \mu\text{m}$; $W=1.7\ \mu\text{m}$; (b) $L=4.8\ \mu\text{m}$; $W=2.4\ \mu\text{m}$; (c) $L=2.9\ \mu\text{m}$; $W=1.2\ \mu\text{m}$.